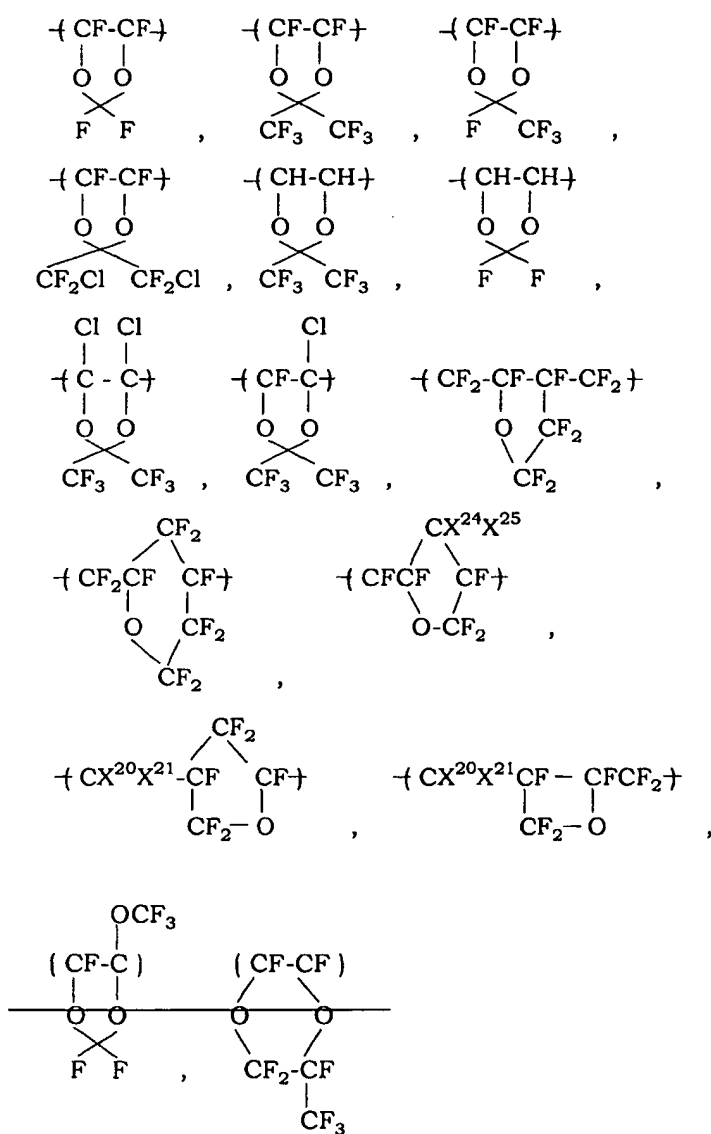
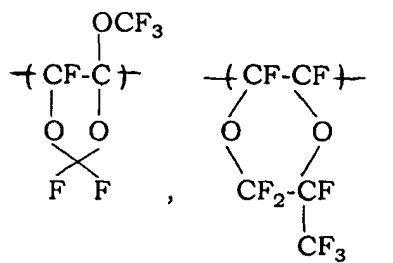


AMENDMENTS TO THE SPECIFICATION

Please replace the paragraph beginning at line 2 bridging pages 28-29 of the specification with the following amended paragraph:

Concretely there are:

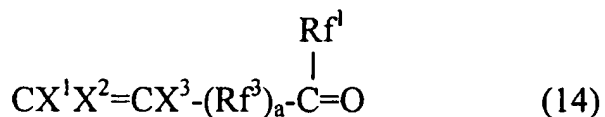
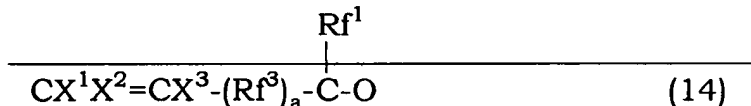




and the like wherein X^{20} , X^{21} , X^{24} and X^{25} are as defined in the formula (17).

Please replace the paragraph beginning at line 21 bridging pages 36-37 of the specification with the following amended paragraph:

The fluorine-containing ethylenic monomer having fluoroalkyl carbonyl group of the present invention is a fluorine-containing monomer represented by the formula (14):



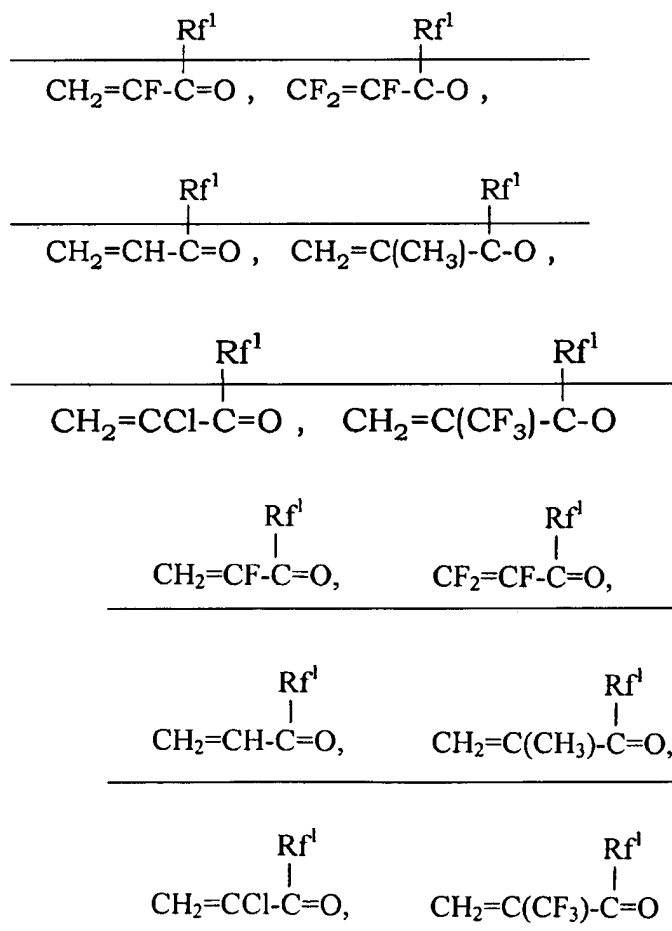
wherein X^1 and X^2 are the same or different and each is H or F; X^3 is H, F, Cl or CF_3 ; Rf^1 is a perfluoroalkyl group having 1 to 20 carbon atoms; Rf^3 is a fluorine-containing alkylene group having 1 to 40 carbon atoms or a fluorine-containing alkylene group having ether bond which has 1 to 100 carbon atoms and the sum of carbon atom and oxygen atom of two or more; a is 0 or 1.

Please replace the second full paragraph beginning at line 8 at page 38 of the specification with the following amended paragraph:

When a is 0, the monomer is one represented by the formula (23):



wherein X^1 and X^2 are the same or different and each is H or F; X^3 is H, F, Cl or CF_3 ; Rf^1 is as defined in the formula (14). More concretely there are:

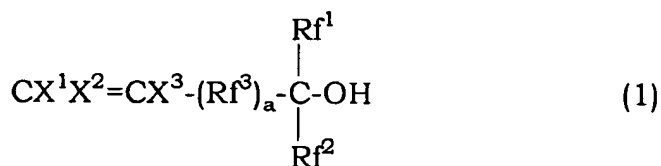


and the like, wherein Rf^1 is as defined in the formula (14).

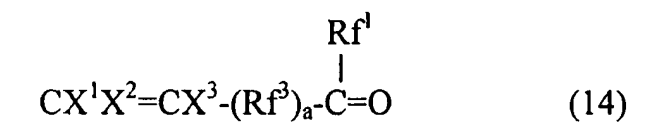
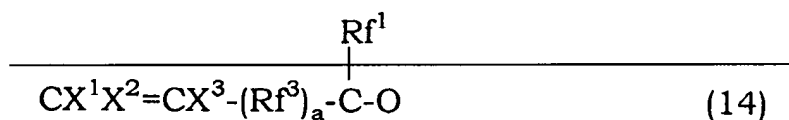
Please delete the present Abstract of the Disclosure.

Please add the following new Abstract of the Disclosure:

There are provided a fluorine-containing ethylenic monomer having hydroxyl group or fluoroalkyl carbonyl group and represented by the formula (1):



and the formula (14):



respectively, wherein X^1 and X^2 are the same or different and each is H or F; X^3 is H, F, Cl or CF_3 ; Rf^1 and Rf^2 are the same or different and each is a perfluoroalkyl group having 1 to 20 carbon atoms; Rf^3 is a fluorine-containing alkylene group having 1 to 40 carbon atoms or a fluorine-containing alkylene group having ether bond which has 1 to 100 carbon atoms and the sum of carbon atom and oxygen atom of two or more; a is 0 or 1, a fluorine-containing polymer having a structural unit of the above-mentioned monomer and a composition for a photoresist. The monomer has good polymerizability, particularly radical polymerizability, and the polymer

obtained by polymerizing the monomer has excellent optical characteristics and is useful as a base polymer for an antireflection film and for a composition for a resist.